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YS

**NONFERROUS METALS INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

YS/T 819-2012

High-purity sputtering copper target used in electronic film

电子薄膜用高纯铜溅射靶材

(English Translation)

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Table of Contents

What this standard covers	1
Document data	2
Standards quoted by this document	3

What this standard covers

This standard specifies the electronic membrane with a high copper sputtering target requirements, test methods, inspection rules and signs, packaging, transportation, storage, quality certificates and contracts (or orders) content. This standard applies

Document data

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